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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/091,373	03/04/2002	Hiroshi Ito	ARC920010125US1	7246	
. 79	590 05/01/2006		EXAMINER		
J. Elin Hartrum REED & ASSOCIATES			WALKE, AMANDA C		
Suite 210	CIATES		ART UNIT	PAPER NUMBER	
800 Menlo Avenue			1752		
Menlo Park, C	A 94025		DATE MAILED: 05/01/2006	DATE MAILED: 05/01/2006	

Please find below and/or attached an Office communication concerning this application or proceeding.

			10
	Application No.	Applicant(s)	
	10/091,373	ITO, HIROSHI	
Office Action Summary	Examiner	Art Unit	
	Amanda C. Walke	1752	
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with the o	correspondence address	
A SHORTENED STATUTORY PERIOD FOR REPLY WHICHEVER IS LONGER, FROM THE MAILING DA - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication If NO period for reply is specified above, the maximum statutory period w - Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be tire will apply and will expire SIX (6) MONTHS from a cause the application to become ABANDONE	N. nely filed the mailing date of this communicatio (C) (35 U.S.C. § 133).	
Status			
1) ☐ Responsive to communication(s) filed on <u>17 Ap</u> 2a) ☐ This action is FINAL . 2b) ☐ This 3) ☐ Since this application is in condition for allowar	action is non-final.	osacution as to the marits i	e
closed in accordance with the practice under E	,		3
Disposition of Claims			
4) ☐ Claim(s) 1-31 is/are pending in the application. 4a) Of the above claim(s) is/are withdray 5) ☐ Claim(s) is/are allowed. 6) ☐ Claim(s) 1-31 is/are rejected. 7) ☐ Claim(s) is/are objected to. 8) ☐ Claim(s) are subject to restriction and/or	vn from consideration.	·	·
Application Papers			
9) The specification is objected to by the Examine 10) The drawing(s) filed on is/are: a) access applicant may not request that any objection to the confidence of the	epted or b) objected to by the drawing(s) be held in abeyance. Section is required if the drawing(s) is ob	e 37 CFR 1.85(a). jected to. See 37 CFR 1.121(d).
Priority under 35 U.S.C. § 119			
 12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority documents 2. Certified copies of the priority documents 3. Copies of the certified copies of the prior application from the International Bureau * See the attached detailed Office action for a list of the certified copies of the certified copies 	s have been received. s have been received in Applicati ity documents have been receive (PCT Rule 17.2(a)).	on No ed in this National Stage	
Attachment(s)	_		
Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date	4) Interview Summary Paper No(s)/Mail Da 5) Notice of Informal P 6) Other:		

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DETAILED ACTION

Response to Arguments

1. Applicant's arguments, filed 4/17/2006, with respect to the rejection(s) of claim(s) 1-31 under U.S.C. 103 have been fully considered and are persuasive. Therefore, the rejection has been withdrawn. However, upon further consideration, a new ground(s) of rejection foolows...

Claim Rejections - 35 USC § 103

- 2. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 3. Claims 1-31 are rejected under 35 U.S.C. 103(a) as being unpatentable over Araki et al (6,908,724).

Araki et al disclose a fluorine-containing polymer for use as a chemically amplified photoresist. The polymer includes a variety of polymers and monomers, and may take the structure: M1-M2-M3-N, wherein M1 is of structure similar to the instant monomer II (see column 147-149), M2 is an alicyclic monomer, M3 is of structure similar to that of the instant monomer I (see column 158-159), and N is selected from monomers such as ethylene, vinyl ether, allyl, or the monomers described in columns 39-41 which are suitable to be combined with the novel fluorine-containing monomers (claim 16). The monomers described in columns 147-149 and 158-159 comprise groups falling within the scope of the instant claims 2-14. The compositions further comprises an acid generator (such as an onium salt as described in columns 62-93), and is a UV, specially VUV resist (157 nm; see abstract). Also, a solvent, an organic

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base, and optionally a crosslinker should the resist be a negative resist. The resist is then employed in a conventional method of forming a resist pattern columns 94-96 and examples in columns 215-219).

Given the teachings of the references, it would have been obvious to one of ordinary skill in the art to prepare the material of Araki et al choosing to employ the M1-M2-M3-N polymer either alone, or in combination with an additional novel polymer taught by the reference, which comprises monomers meeting the structural limitations of the instant monomers I and II, with reasonable expectation of achieving a material having high etching resistance.

Conclusion

4. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Takechi et al (6,329,125), Hatakeyama et al (6,835,524), and Ito et al (6,548,219) are cited for their teachings of similar monomers.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Amanda C. Walke whose telephone number is 571-272-1337. The examiner can normally be reached on M-R 5:30-4.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Cynthia Kelly can be reached on 571-272-1526. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Amanda C Walke Primary Examiner Art Unit 1752

ACW April 28, 2006